

Computational discovery of p-type transparent oxide semiconductors using hydrogen descriptor

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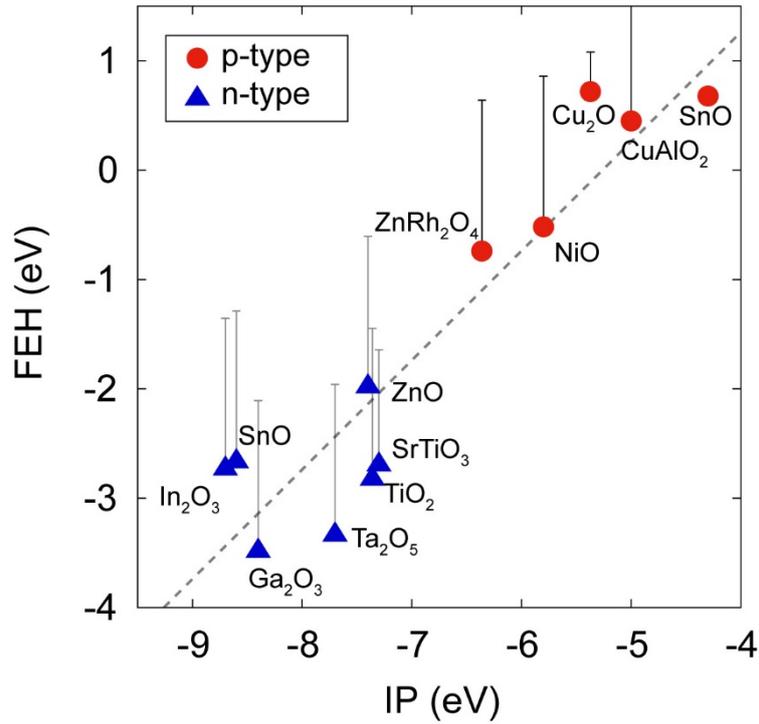


Figure S1. FEH versus experimental ionization potential. The grey error-bars represent the variation of FEH with O₂ pressure under the condition that each phase is stable. The upper (lower) limit of each error bar corresponds to the oxygen-rich (oxygen-poor) conditions.¹⁻⁴

If the material is stable in all O₂ partial pressure (P_{O_2}), the hydrogen chemical potential can differ by up to 1.38 eV (highest in the O-rich condition). However, P_{O_2} is often limited in the range where the considered material is stable. For example, SnO is not stable even in a very low oxygen chemical potential since SnO₂ phase is very stable. To avoid the complexity involved in determining the oxygen chemical potential, we defined FEH by fixing the hydrogen chemical potential to that of H₂ gas (i.e., O-poor condition). If we instead considered O-rich condition in calculating FEH, the values can vary as the shown in Fig. S1. Even if we use the highest FEH values in Fig. S1, it is seen that the p-type oxides still cluster in the region of FEH > 0 eV.

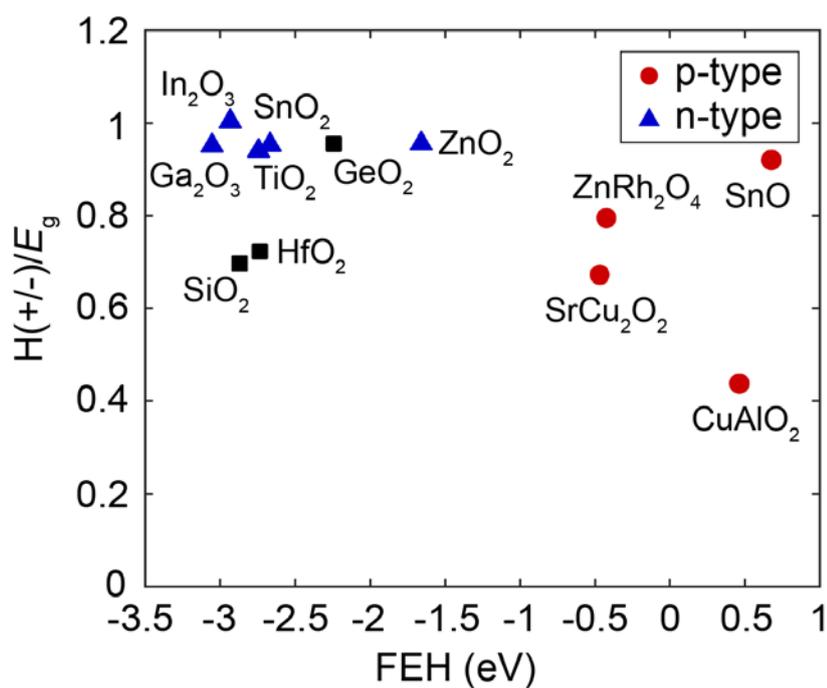


Figure S2. FEH versus $H(+/-)/E_g$ level computed within the hybrid functional.

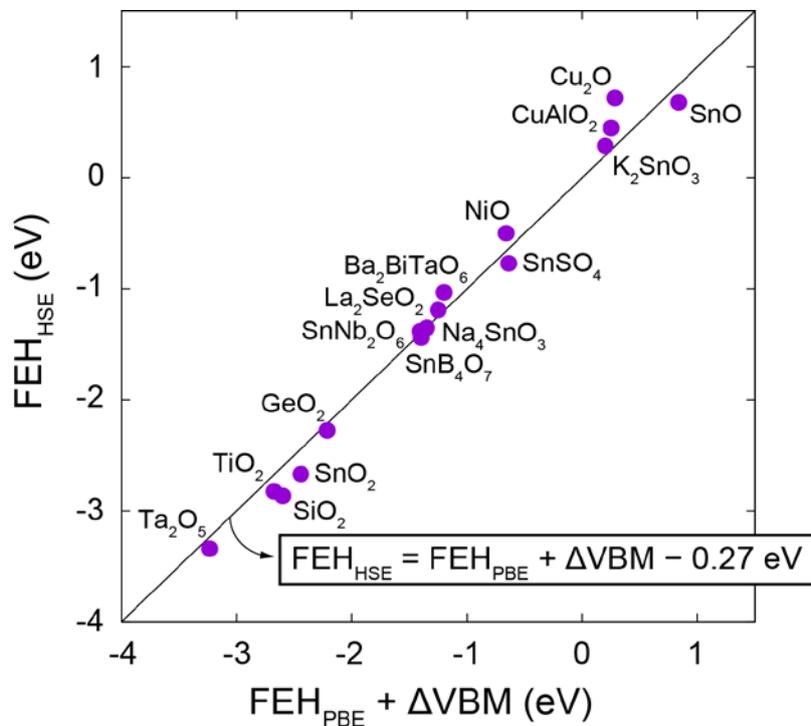


Figure S3. Comparison of FEH using PBE functional with VBM correction and full HSE functional.

Stable H_i^+ site in oxides. To search the stable H_i^+ site in oxides, we test various configurations including anti-bonding sites, bond-center sites, and void sites found from Voronoi vertices. As an example, supercell of $SnNb_2O_6$ and the relaxed H_i^+ sites starting from the various initial configurations are shown in Fig. S4. We find that the H_i^+ always prefer to form O-H bond through relaxation and the most stable O-H bond is lie in the direction of the maximum Coulomb potential around the oxygen in all our test calculations. We also test the cases of multiple anion system such as La_2O_2Te and $LaCuOSe$ and confirm that O-H bond is always more stable than the bond with other anion atoms.

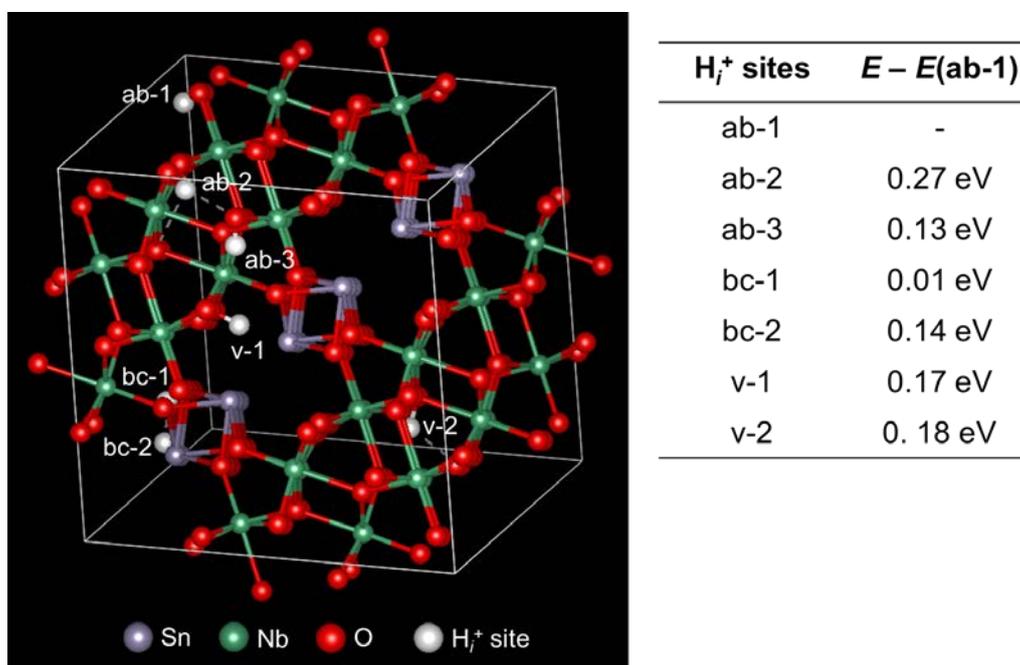


Figure S4. Supercell structure of $SnNb_2O_6$ and the relaxed H_i^+ sites from the considered initial configurations. The labels on H_i^+ sites indicate the types of initial configurations (ab: antibonding sites, bc: bond center sites, v: void sites) The relative energy of each H_i^+ configurations compared to the most stable configuration are shown in the right table.

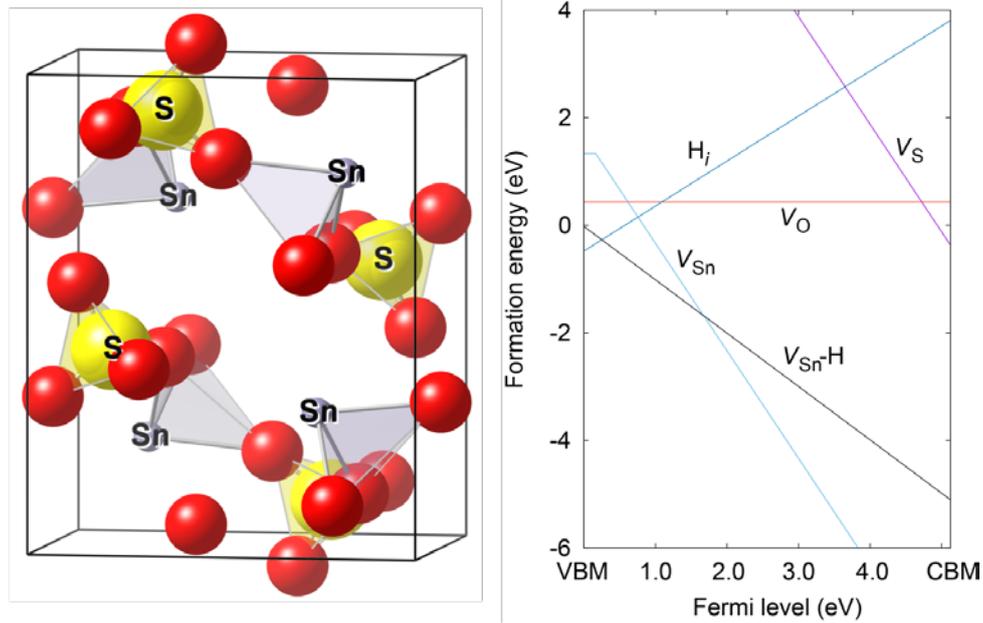


Figure S5. Crystal structure and formation energies of intrinsic and hydrogen-related defects of SnSO₄ in the oxygen-rich condition.

Note: The nominal charge of Sn, S, and O in SnSO₄ would be +2, +6, and -2, respectively. The high-valence state of S may question the transferability of PAW pseudopotential in which the core shells (1s, 2s, and 2p) are frozen. However, in Ref. S5, Fe(hydro)oxide-H₂O interface with SO₄²⁻ ligand was studied with both VASP and all-electron code (Gaussian) and it was found that the interatomic distances and angles of both calculation agree well with experiments. In another literature, Ref. S6 and Ref. S7 employed the same type of pseudo-potential for materials containing (SO₄)²⁻ and their results showed good agreements with experimental structures and energetics. Therefore, we believe that the VASP PAW potential works well for SnSO₄.

Supplementary References

1. Stevanović, V., Lany, S., Ginley, D. S., Tumas, W. & Zunger, A. Assessing capability of semiconductors to split water using ionization potentials and electron affinities only. *Phy. Chem. Chem. Phys.* **16**, 3706–14 (2014).
2. Robertson, J. Band offsets of wide-band-gap oxides and implications for future electronic devices. *J. Vac. Sci. Technol. B* **18**, 1785 (2000).
3. Xiong, K., Robertson, J. & Clark, S. J. Behavior of hydrogen in wide band gap oxides. *J. Appl. Phys.* **102**, 83710 (2007).
4. Pelatt, B. D., Ravichandran, R., Wager, J. F. & Keszler, D. A. Atomic solid state energy scale. *J. Am. Chem. Soc.* **133**, 16852–16860 (2011).
5. Paul, K. W., Kubicki, J. D. & Sparks, D. L. Sulphate adsorption at the Fe (hydr)oxide–H₂O interface: comparison of cluster and periodic slab DFT predictions. *Eur. J. Soil. Sci.* **58**, 978-988 (2017).
6. Derzsi, M., *et al.* Redetermination of crystal structure of Ag(II)SO₄ and its high-pressure behavior up to 30 GPa. *Cryst. Eng. Comm.* **15**, 192-198 (2013).
7. Clark, J. M., *et al.* High voltage sulphate cathodes Li₂M(SO₄)₂ (M = Fe, Mn, Co): atomic-scale studies of lithium diffusion, surfaces and voltage trends. *J. Mater. Chem. A* **2**, 7446 (2014).